Pursuant to 37 CFR §1.121, a marked-up version of amended Claims 3 and 5-7 is attached hereto showing the changes made by the current amendment.

REMARKS

This amendment amends Claims 3 and 5-7 to eliminate multiple dependencies so as to reduce the filing fee. Please enter this amendment before calculating the filing fee.

Respectfully submitted

Dale H. Thiel

DHT/jp

Dale H. Thiel Reg. No. 24 323 FLYNN, THIEL, BOUTELL David G. Boutell Reg. No. 25 072 & TANIS, P.C. Ronald J. Tanis Reg. No. 22 724 2026 Rambling Road Kalamazoo, MI 49008-1699 Terryence F. Chapman Reg. No. 32 549 Phone: (616) 381-1156 Mark L. Maki Reg. No. 36 589 David S. Goldenberg (616) 381-5465 Reg. No. 31 257 Fax: Sidney B. Williams, Jr. Reg. No. 24 949 Reg. No. 40 694 Liane L. Churney Brian R. Tumm Reg. No. 36 328 Tricia R. Cobb Reg. No. 44 621

Encl: Marked-up version of Claims 3 and 5-7

111.9803

Express Mail No. EL 697 493 639 US Applicant: Okimitsu YASUDA et al. Atty. Ref.: OPS Case 555

November 7, 2001

Page 1

Claims 3 and 5-7 have been amended as follows:

- 3. (Amended) The sulfuric acid recycle apparatus according to Claim 1—or—2, wherein the reaction bath includes therein a plurality of partition plates for changing an advancing direction of the wafer cleaning waste fluid, and an inclination plate positioned at a portion closer to the gas discharge port than the partition plates for allowing the concentrated sulfuric acid to flow along the surface thereof.
- 5. (Amended) The sulfuric acid recycle apparatus according to any of Claims 1 to 4Claim 1, wherein the reaction bath has a waterdrop storage bath for preventing waterdrop attached to a ceiling surface of the reaction bath from being mixed with the concentrated sulfuric acid.
- 6. (Amended) The sulfuric acid recycle apparatus according to any of Claims 1 to 5Claim 1, wherein fresh sulfuric acid is supplied to the concentrated sulfuric acid.
- 7. (Amended) The sulfuric acid recycle apparatus according to any of Claims 2 to 6Claim 2, wherein a heating temperature in the reaction bath ranges from 150°C to 350°C.